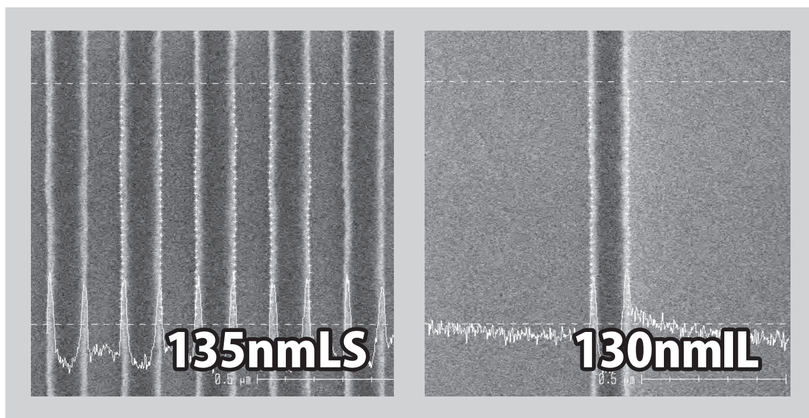
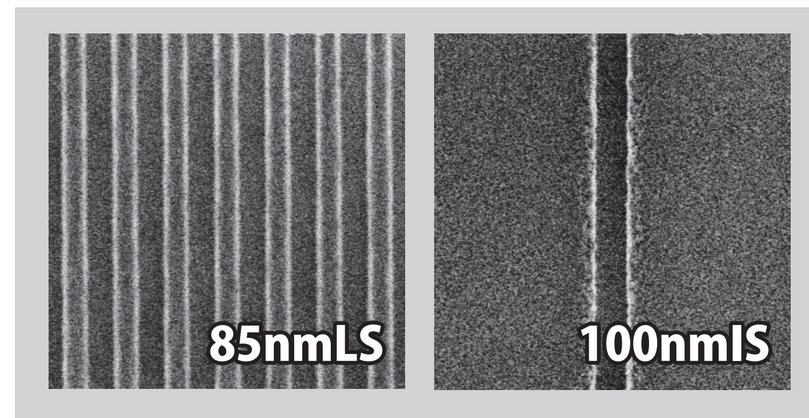
JSR ArF Lithography Materials

ArF Immersion Photoresist Series





LS

Pattern size

200 — **ARX3500JN** (Dry on SiO2 for Implant)

120 — **ARX2772JN** (Dry)

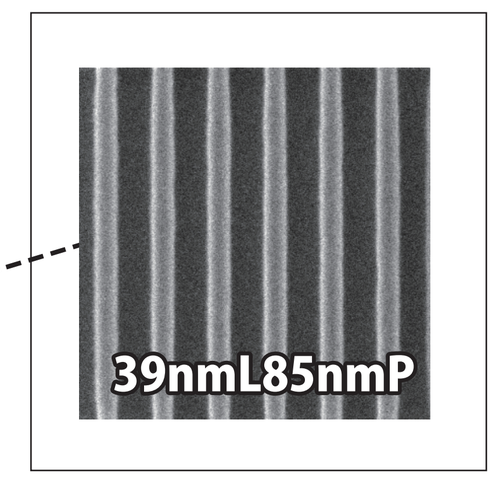
AIM9310JN (NonTC)

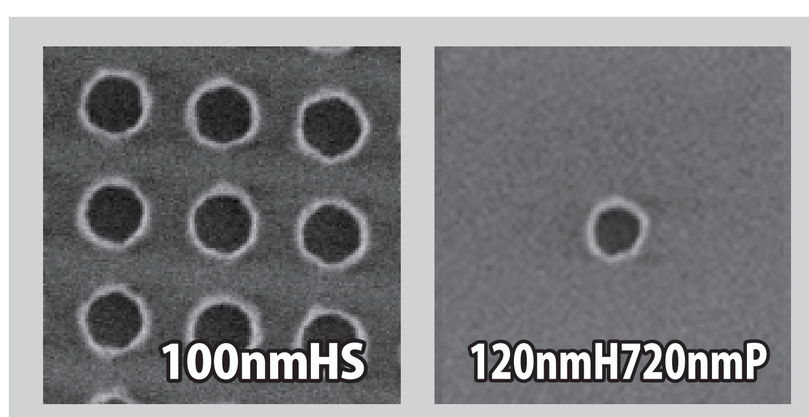
65 — **AEX2936J** (NonTC)

AEX2055JN (NonTC)

40

Dense → Iso (BF/DF)





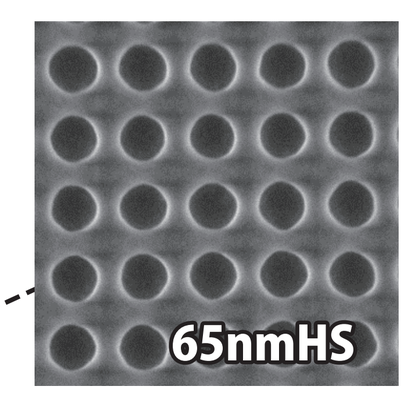
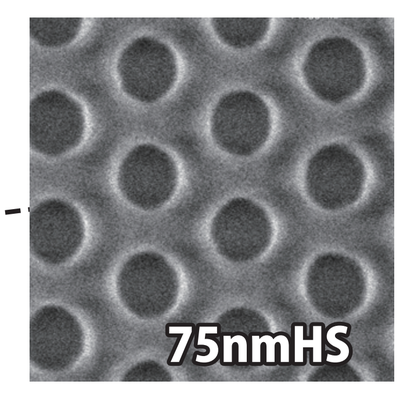
CH

Pattern size

150 — **ARX2772JN** (Dry)

100 — **AIM6779JN** (w/TC)

AEX3791J (Non TC)

60

Dense → Iso (BF/DF)